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(12) **United States Design Patent** (10) **Patent No.:** **US D976,494 S**
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(54) **SANITARY MASK**
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(52) **U.S. Cl.**
USPC **D29/108**

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D29/105, 107, 108, 110, 129
CPC A41D 13/11; A41D 13/1107; A41D
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See application file for complete search history.

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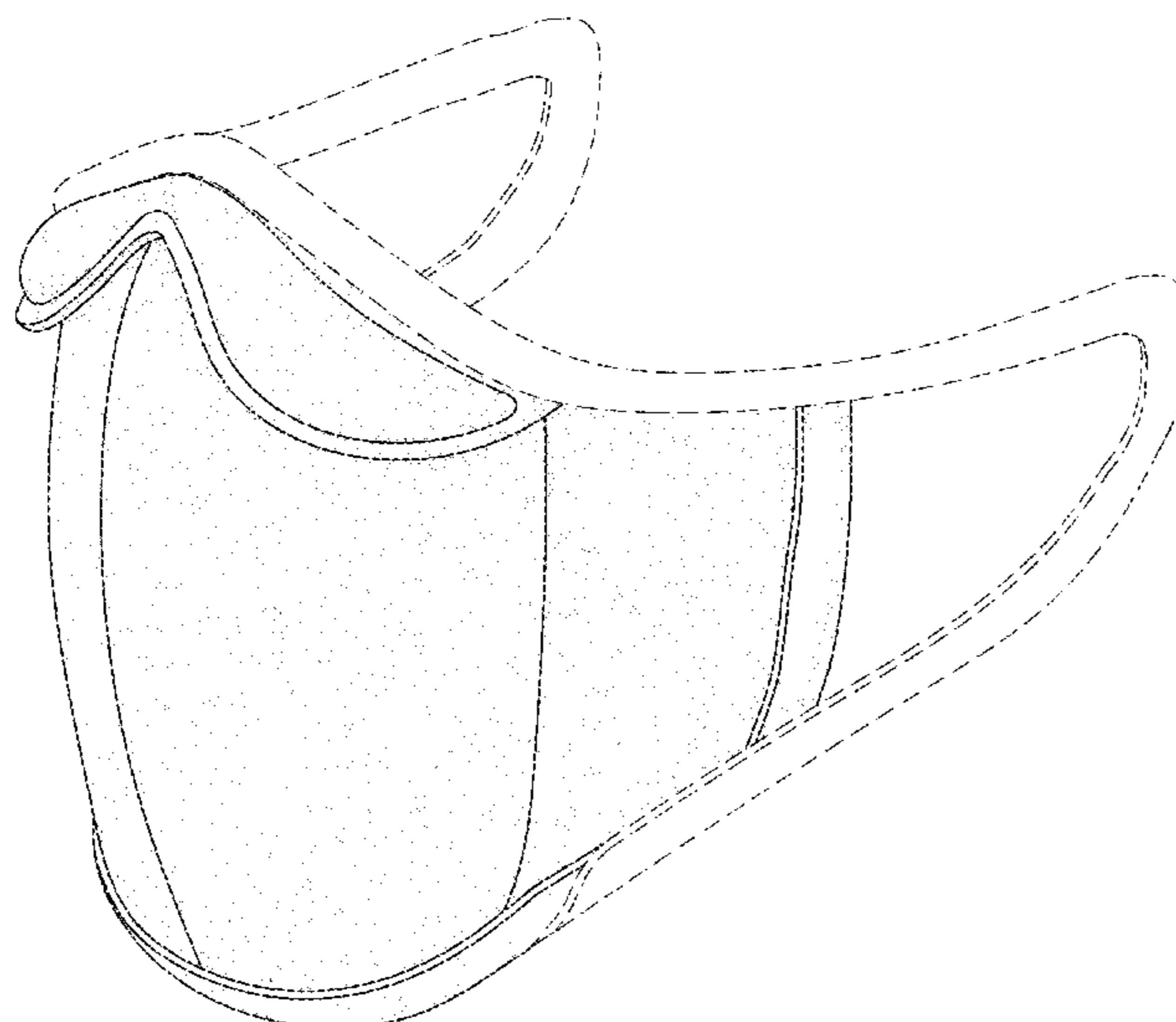
(57) **CLAIM**

The ornamental design for sanitary mask, as shown and
described.

DESCRIPTION

FIG. 1 is a perspective view;
FIG. 2 is a front view;
FIG. 3 is a left side view;
FIG. 4 is a right side view;
FIG. 5 is a back view;
FIG. 6 is a top view; and,
FIG. 7 is a bottom view.
Elements shown in broken lines show portions of the
sanitary mask that form no part of the claimed design.

1 Claim, 7 Drawing Sheets



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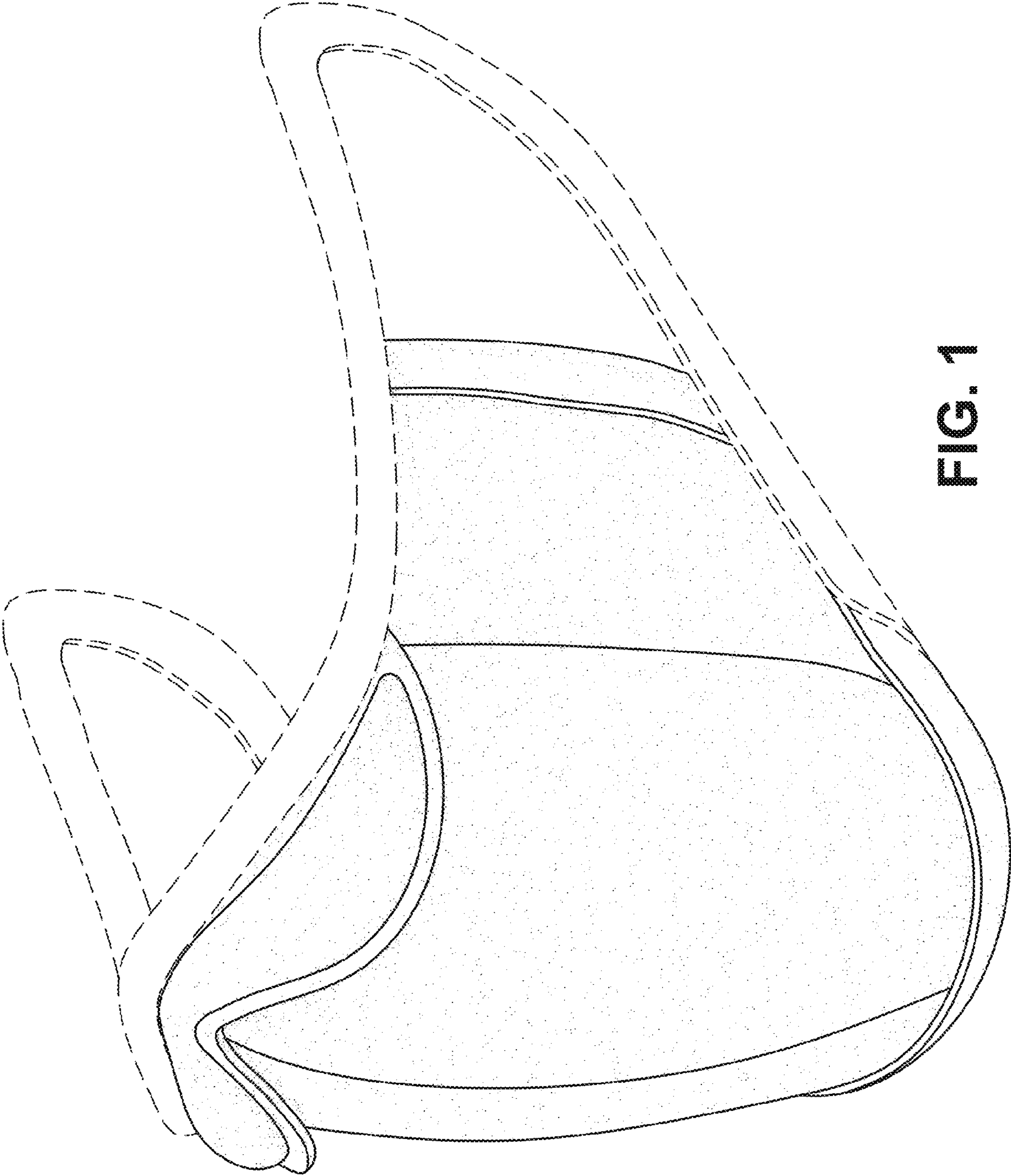


FIG. 1

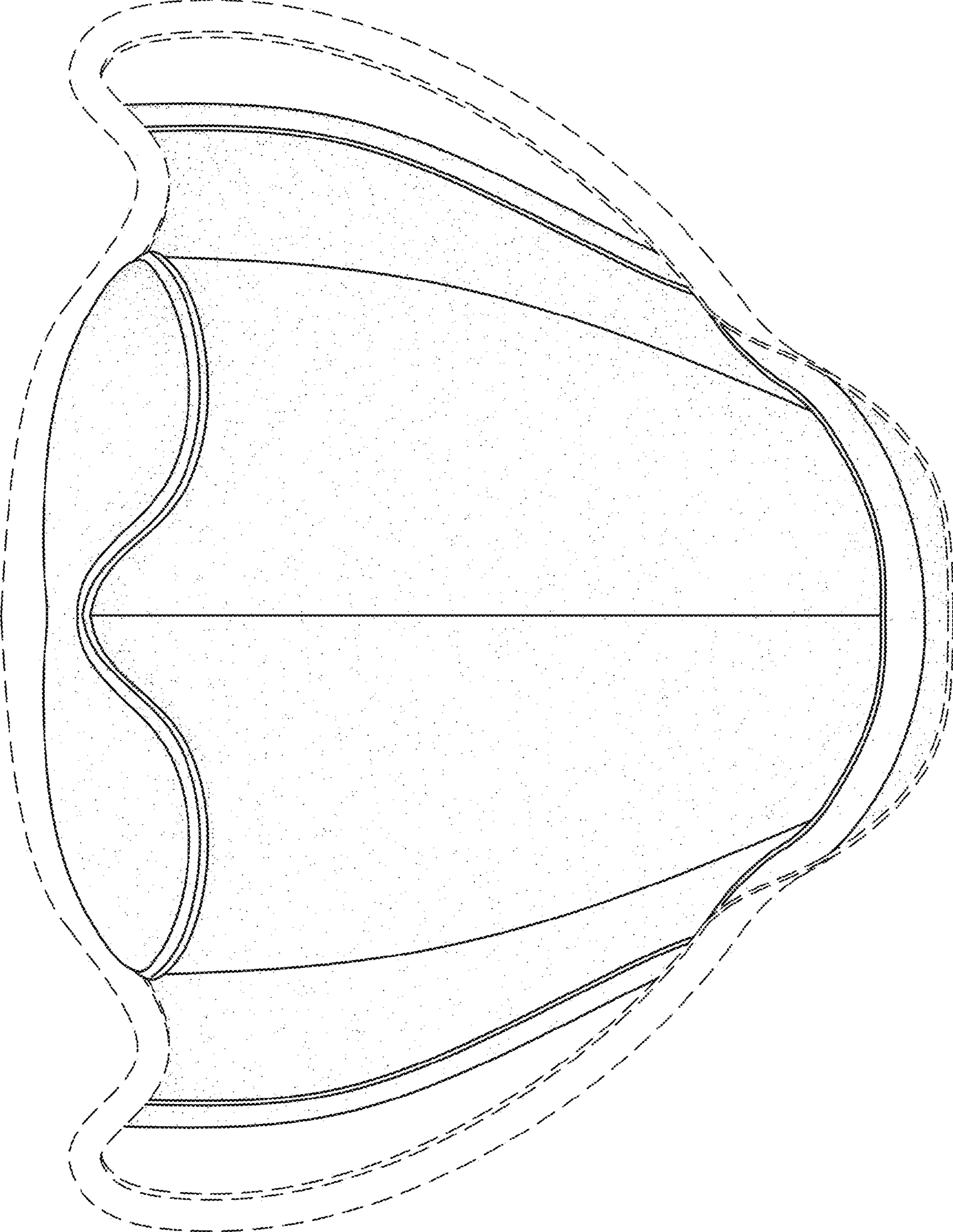


FIG. 2

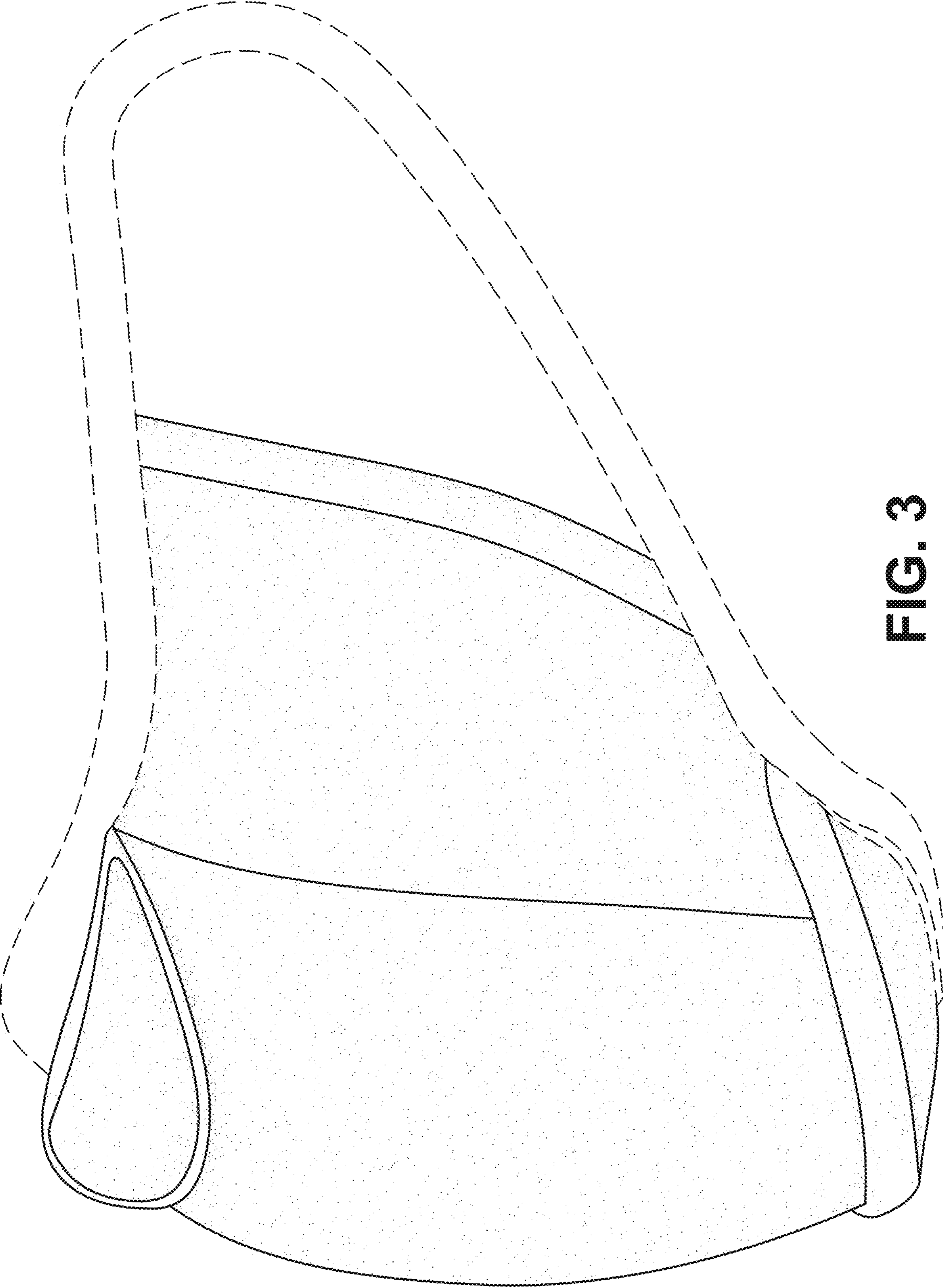


FIG. 3

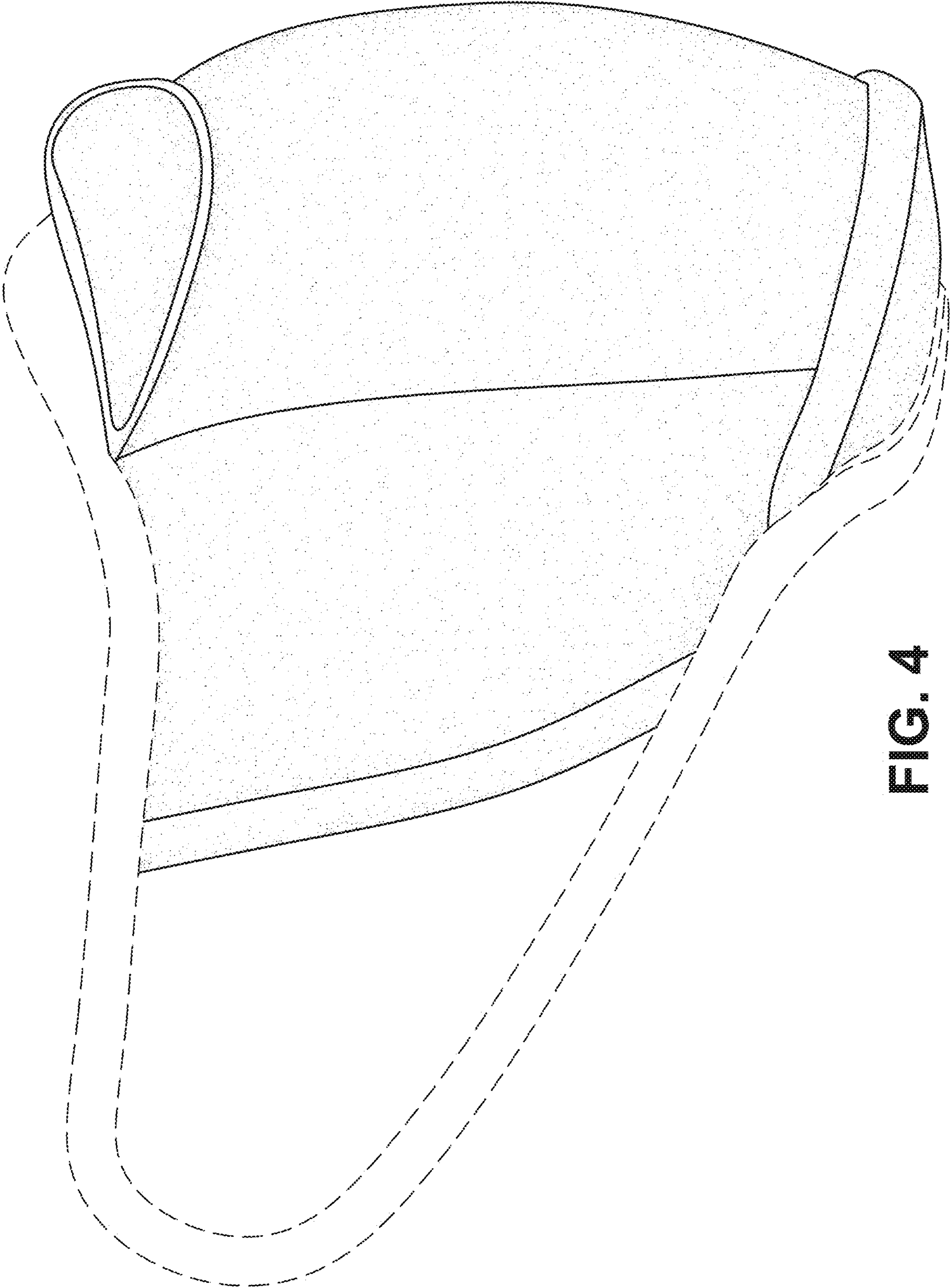


FIG. 4

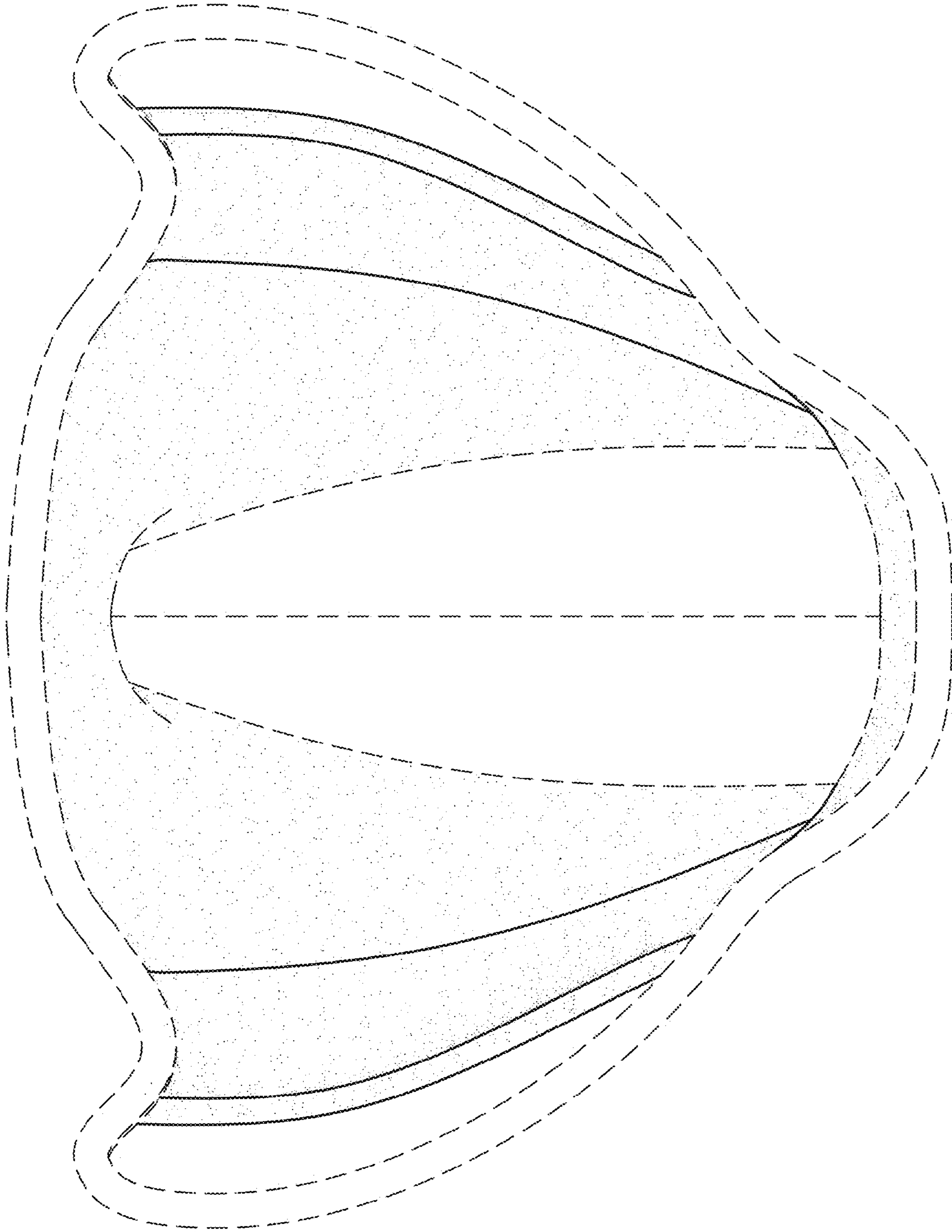


FIG. 5

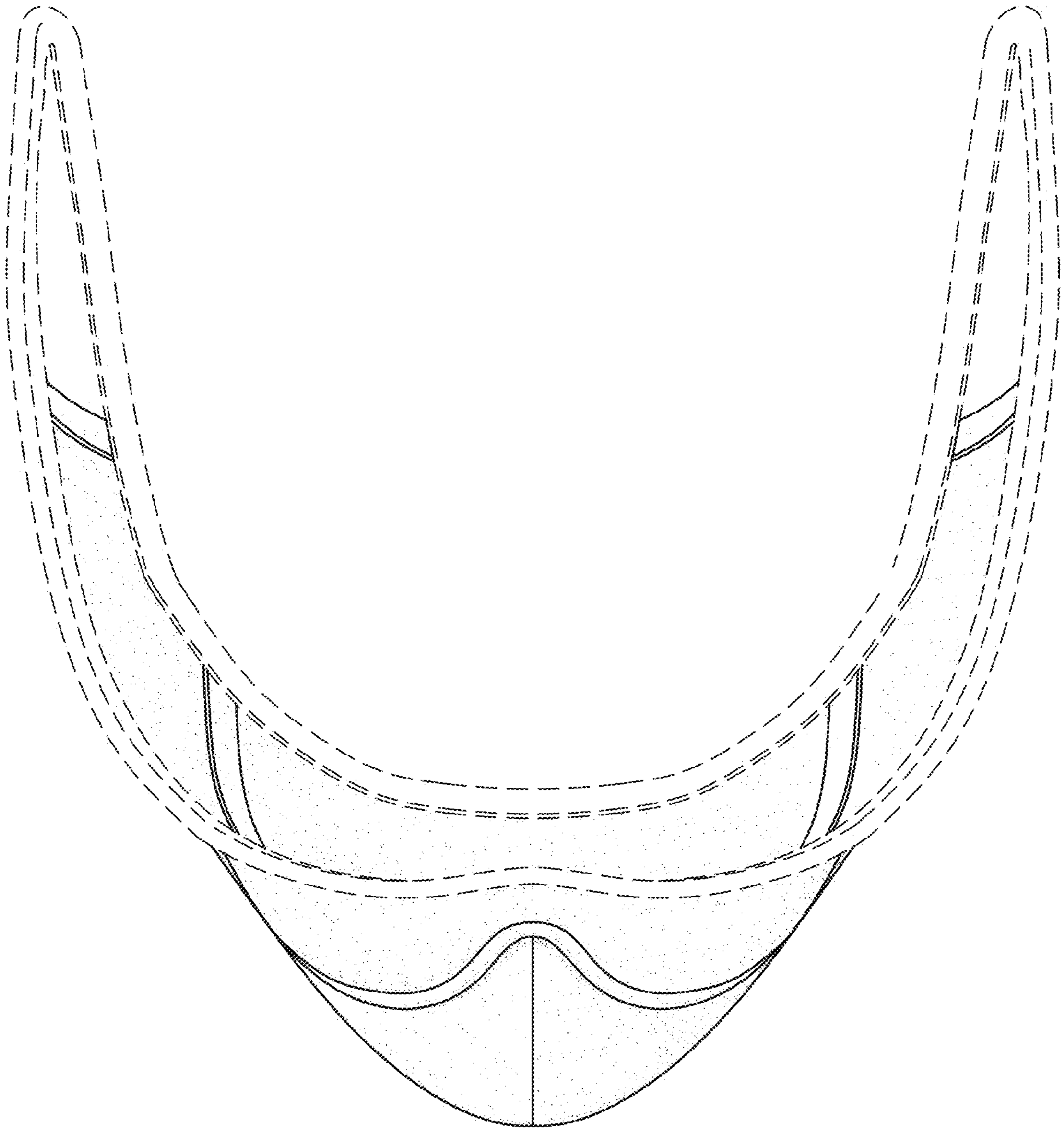


FIG. 6

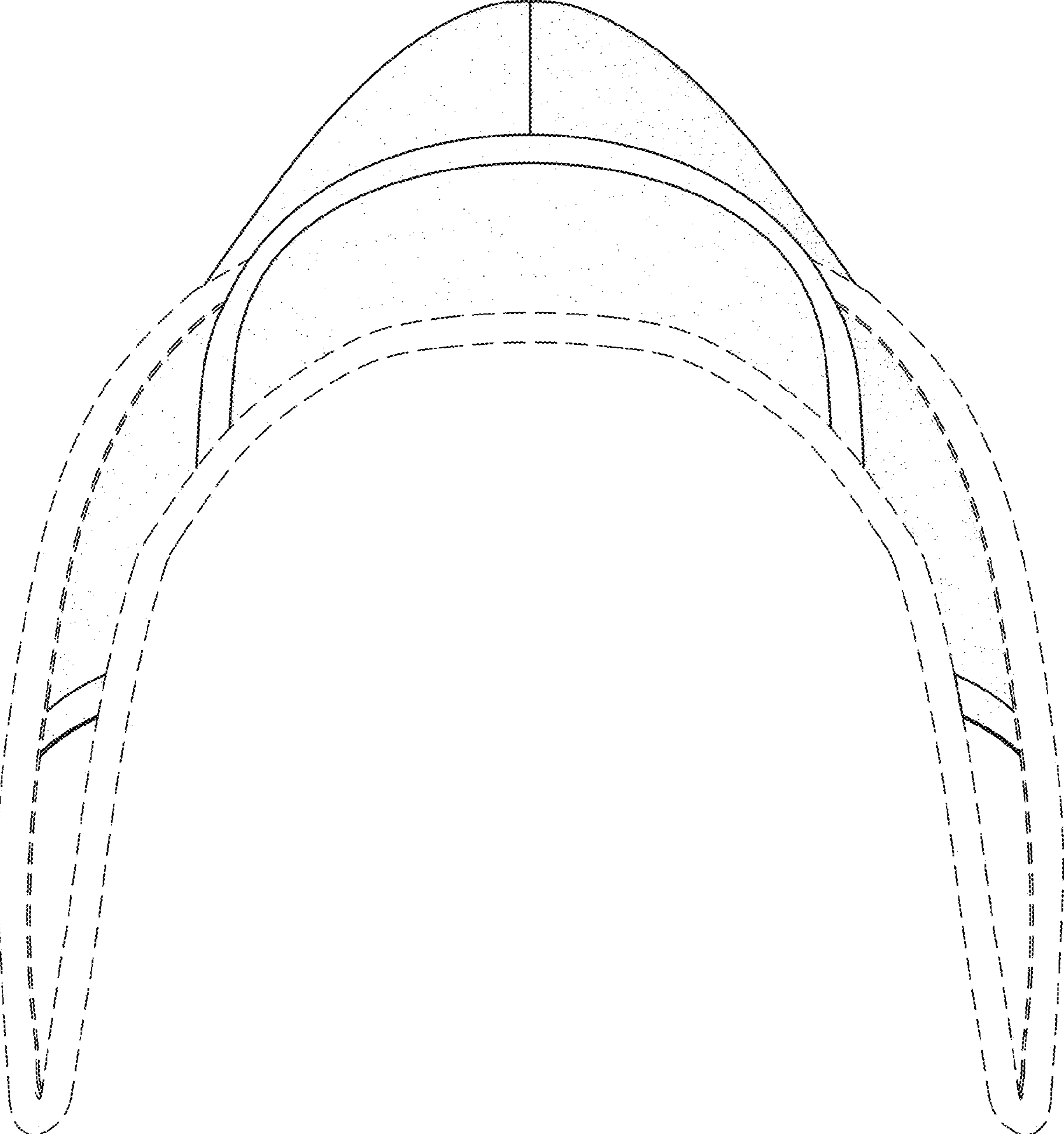


FIG. 7